

# COMPARISON OF UV AND EB PROCESSING ON STRUCTURE PROPERTY RELATIONSHIPS

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# SIMILAR BUT NOT THE SAME

UV



EB



- ❖ UV allows for easier controls of processing parameters
- ❖ EB has higher energy and can alter polymerization mechanism and processing

# RADIATION CURE BENEFITS



- ✦ Green technology
- ✦ No solvent waste
- ✦ Low hazard

✦ Very low  
VOC emissions



- ✦ Process efficiency and flexibility
- ✦ Room-temperature curing
- ✦ Low heat generation
- ✦ Simple adaptation to existing lines
- ✦ Ease of cleaning

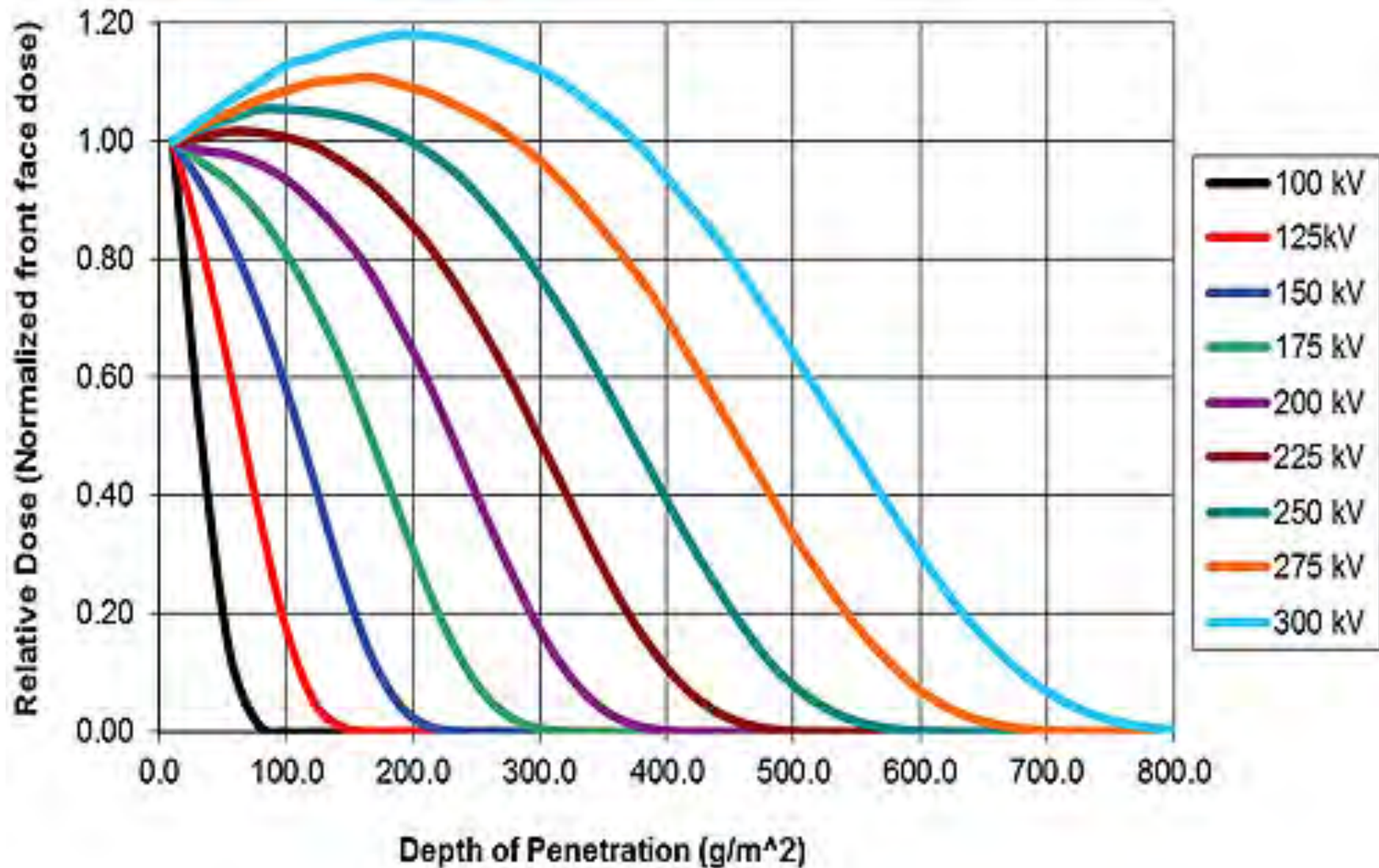
✦ 10 times less space utilization  
than a conventional drying  
oven



- ✦ High productivity and cost savings
- ✦ Reduced cycle time
- ✦ Increased throughput
- ✦ Instant on/off
- ✦ Low energy consumption
- ✦ No solvent waste recycling
- ✦ Minor maintenance cost

✦ 4 times less energy consumption  
than thermal curing

# DEPTH / DOSE CURVES



# EFFECTIVE ELECTRON PENETRATION AT HIGH VOLTAGES

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High Voltage kV	Depth Mils	Depth Gm/M <sup>2</sup>
90	0.8	20.0
110	1.2	30.0
125	1.8	45.0
150	3.5	90.0
175	5.0	125.0
200	7.0	175.0
250	11.0	275.0
300	16.0	400.0

## EB: IMPROVED DOT GAIN CONTROL

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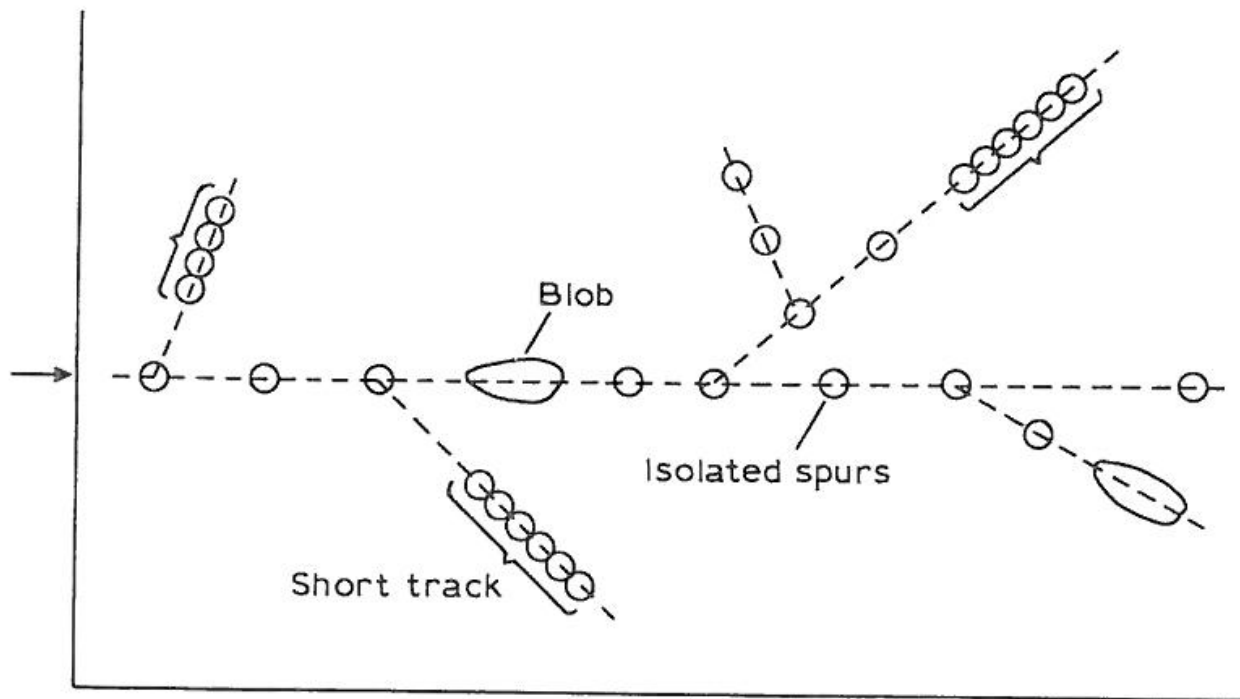
Conventional  
Ink Dot Gain



EB  
Ink Dot Gain

# INTERACTION WITH MATTER AND INITIATION MECHANISM WITH ACRYLATES

Energy loss events along the trajectory of a charged particle ( "string of beads" )



**Fig. 9.12.** Schematic diagram of track entities.

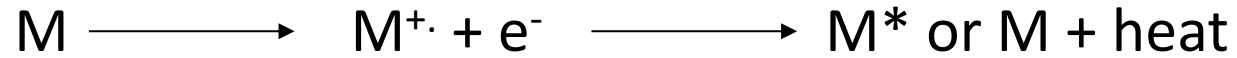
Energy deposited:

- « spurs » < 100 eV
- « Blobs » 100 to 500 eV
- « Tracks » 500 to 5000 eV

Bond ⇄	Bond ⇄	Bond-dissociation energy at 298 K		
		(kcal/mol) ⇄	(kJ/mol) ⇄	(eV/Bond) ⇄
H <sub>3</sub> C-H	Methyl C-H bond	105	439	4.550
C <sub>2</sub> H <sub>5</sub> -H	Ethyl C-H bond	101	423	4.384
(CH <sub>3</sub> ) <sub>2</sub> CH-H	Isopropyl C-H bond	99	414	4.293
(CH <sub>3</sub> ) <sub>3</sub> C-H	<i>t</i> -Butyl C-H bond	96.5	404	4.187
(CH <sub>3</sub> ) <sub>2</sub> NCH <sub>2</sub> -H	C-H bond α to amine	91	381	3.949
(CH <sub>2</sub> ) <sub>3</sub> OCH-H	C-H bond α to ether	92	385	3.990

Source: wikipedia

# INITIATION MECHANISM WITH ACRYLATES



ROH, H<sub>2</sub>O, ..

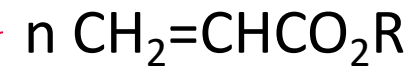
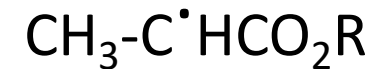


Branching & crosslinking

Scission



ROH, H<sub>2</sub>O, ..



Polymer

Extent of C-C bond cleavage to C-H bond cleavage as a function of chain branching

	n-Hexane	3-Methyl-pentane	2,3-Dimethyl-butane	2,2-Dimethyl-butane
$\frac{G(\text{C-C})}{G(\text{C-H})}$	0.3	0.7	1.4	2.5

# INHIBITION / RETARDATION OF EB ACRYLATE POLYMERIZATION

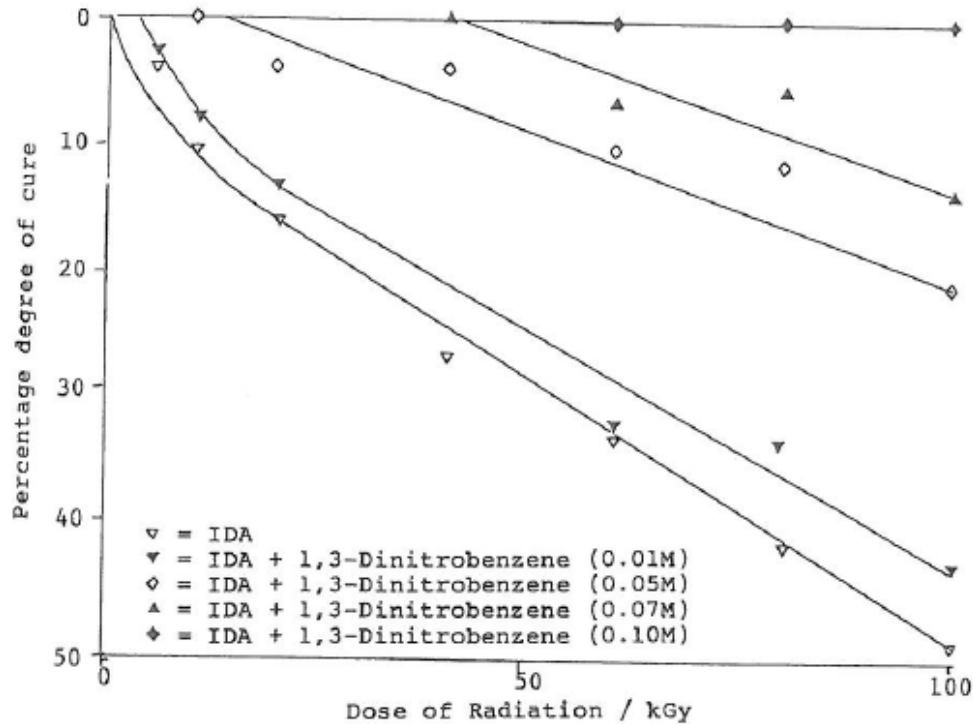
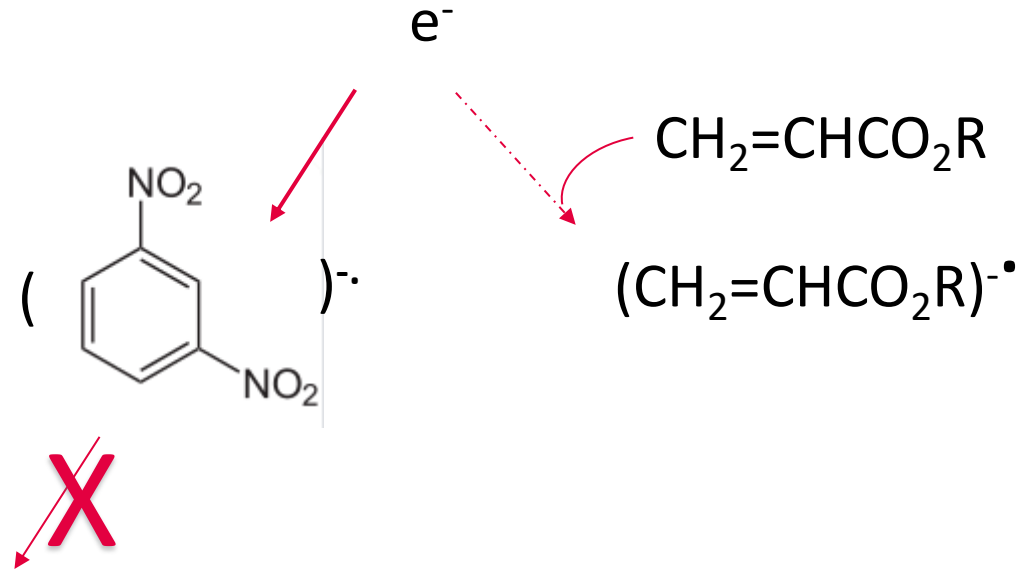


Fig. 9.19. Percentage degree of cure of IDA in the presence of 1,3-dinitrobenzene at various doses of radiation.



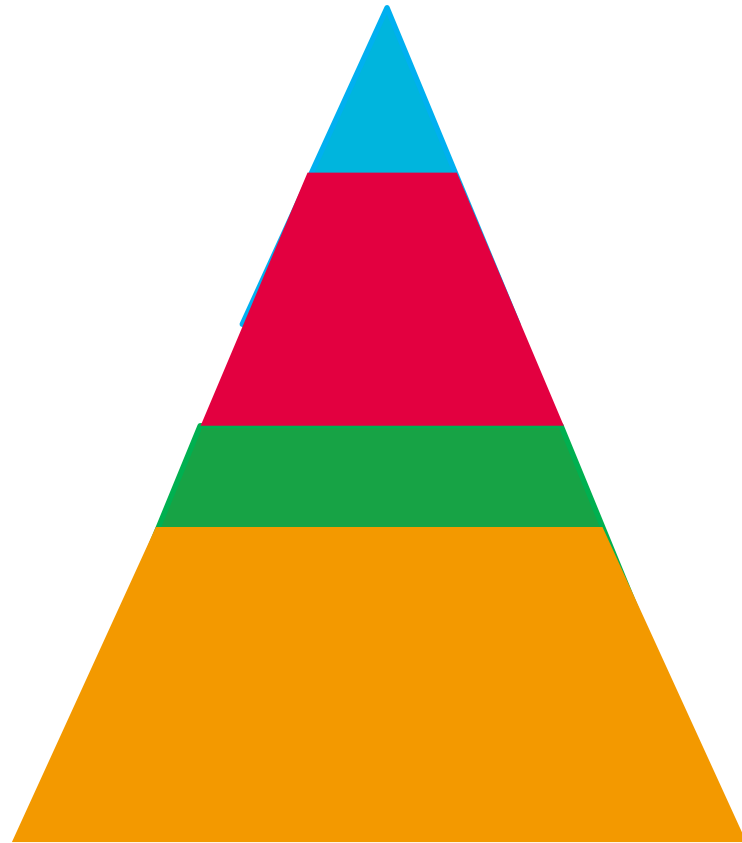
Polymer

Aromatics with electron withdrawing groups

- Pigments based on quinones, azo dyes, phthalocyanines ... ?
- Vinyl aromatics ?
- Unsaturated esters ?

# FORMULATION FOR UV AND EB

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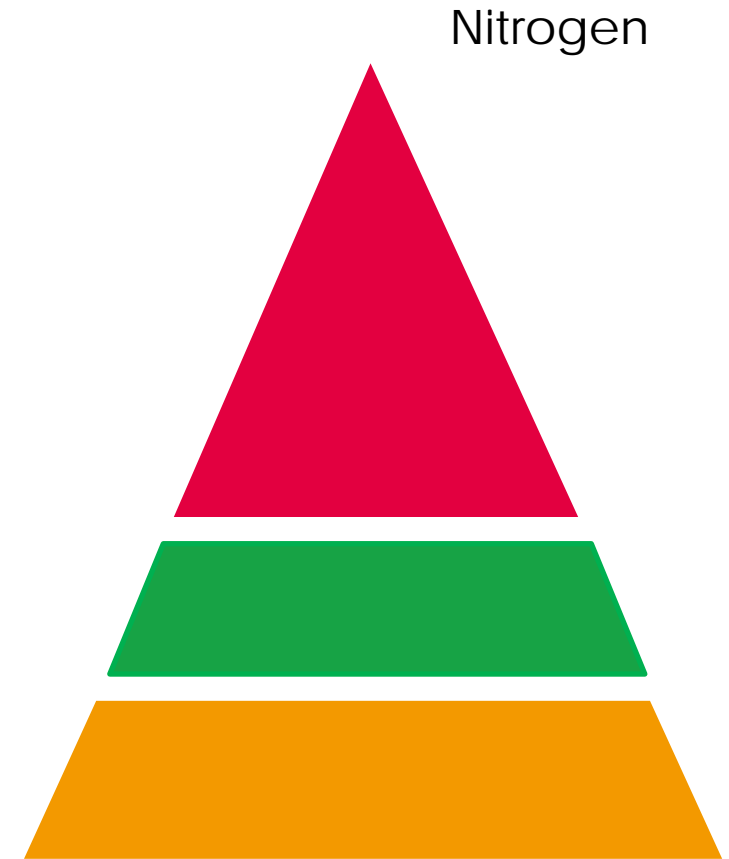
UV and UV-LED

Photoinitiator

Additives & pigments

Monomers

Oligomers



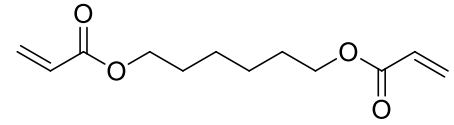
EB



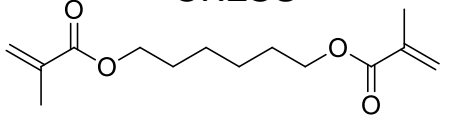
# MONOMER STUDIES

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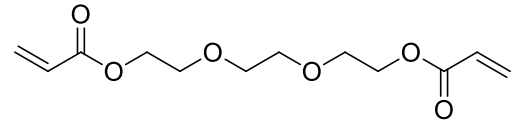
# DIFUNCTIONAL MATERIALS - CURE



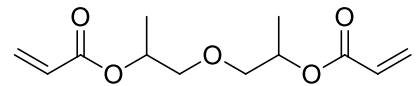
SR238



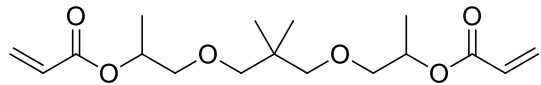
SR239



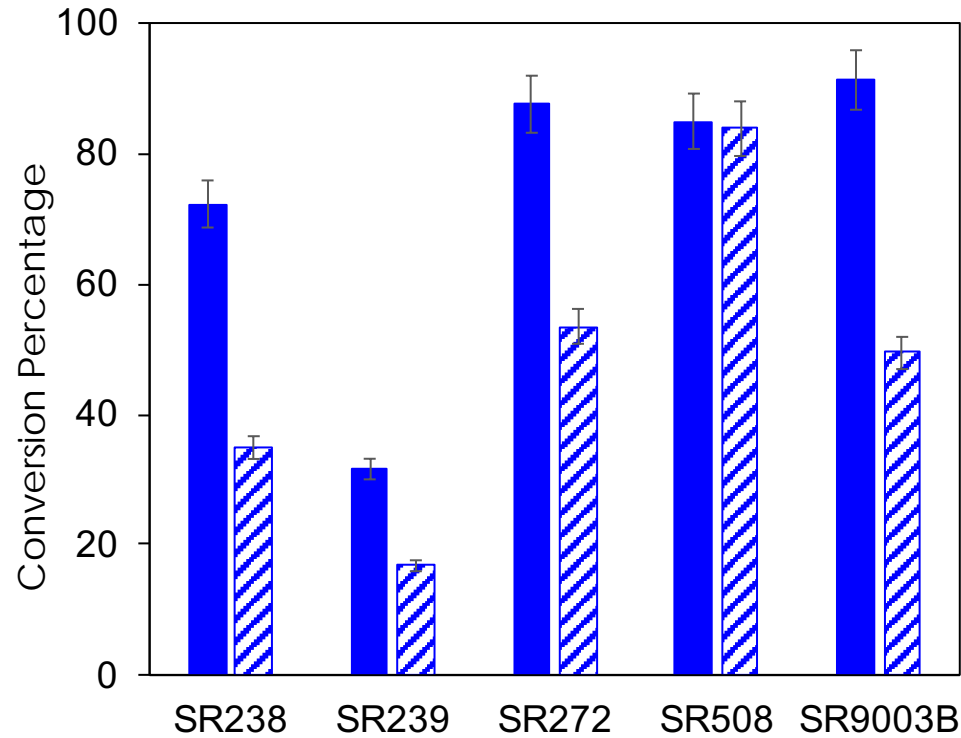
SR272



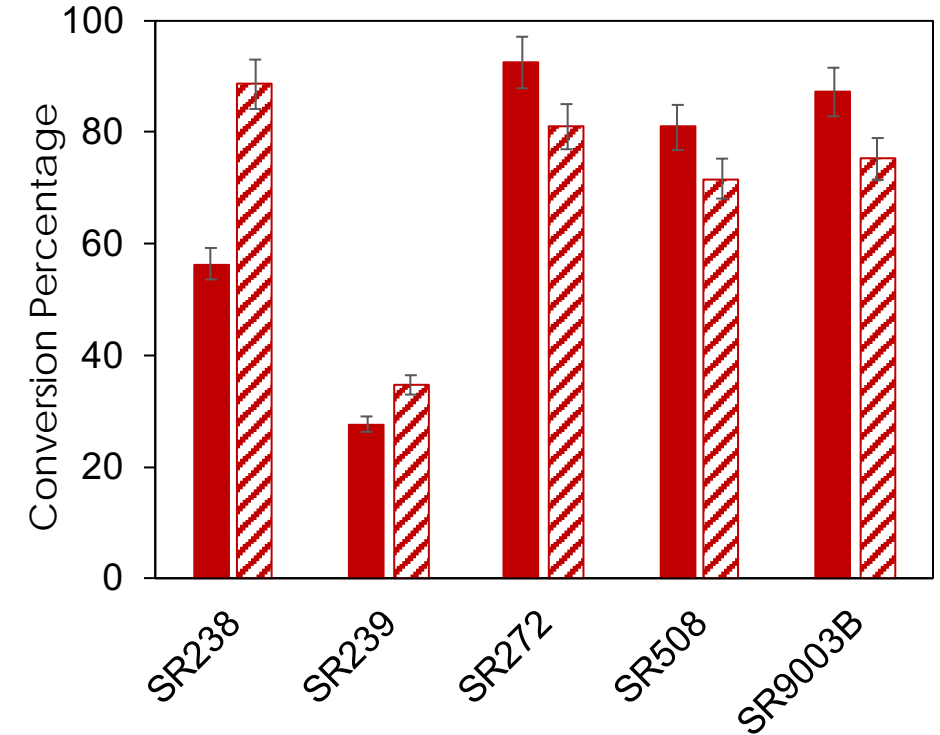
SR508



SR9003B

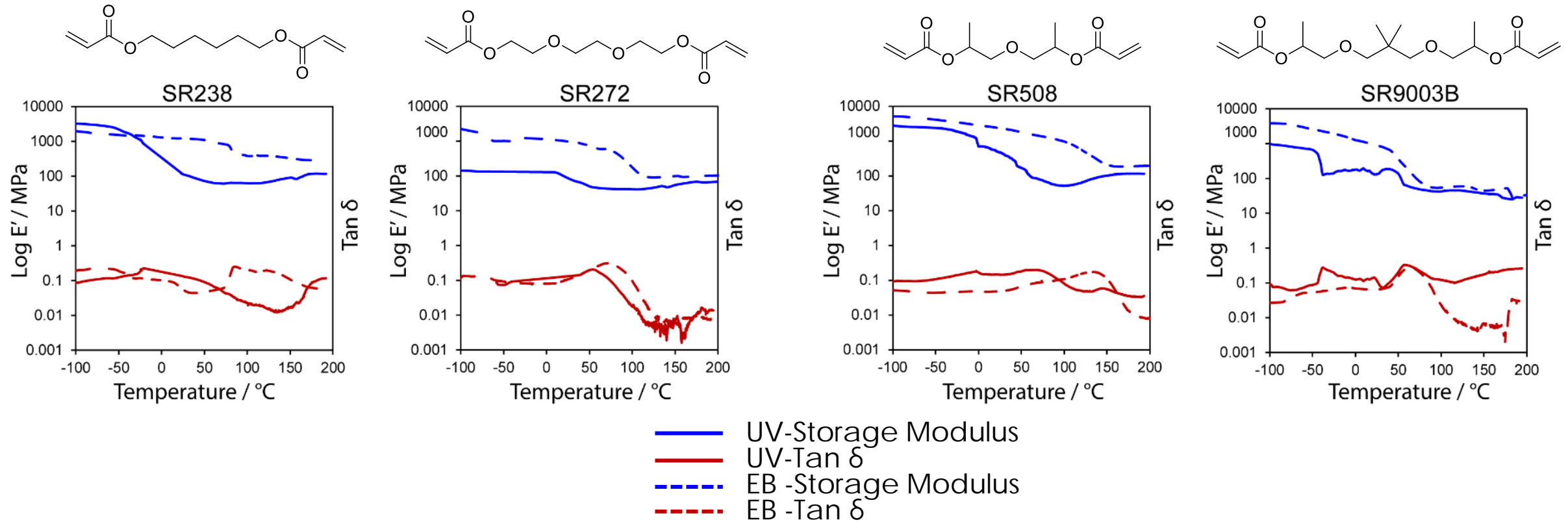


UV cured film top surface  
 UV cured film bottom surface



EB cured film top surface  
 EB cured film bottom surface

# DIFUNCTIONAL - TG

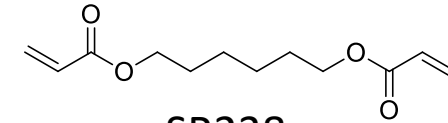


✦ Alterations to curing mechanism through increased side reactions lead to increased modulus and  $T_g$

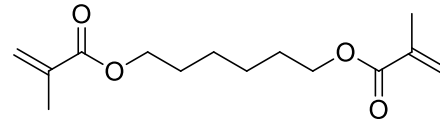
# DIFUNCTIONAL HARDNESS/TENSILE

✦ Increased crosslinking from side reactions through monomer choice increases hardness

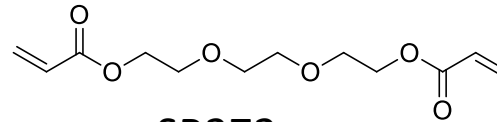
✦ Solvent resistance for neat monomers remains low



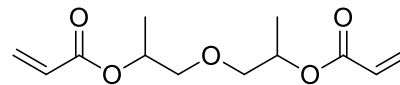
SR238



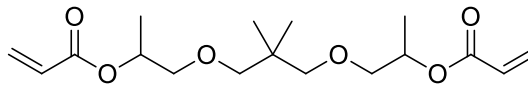
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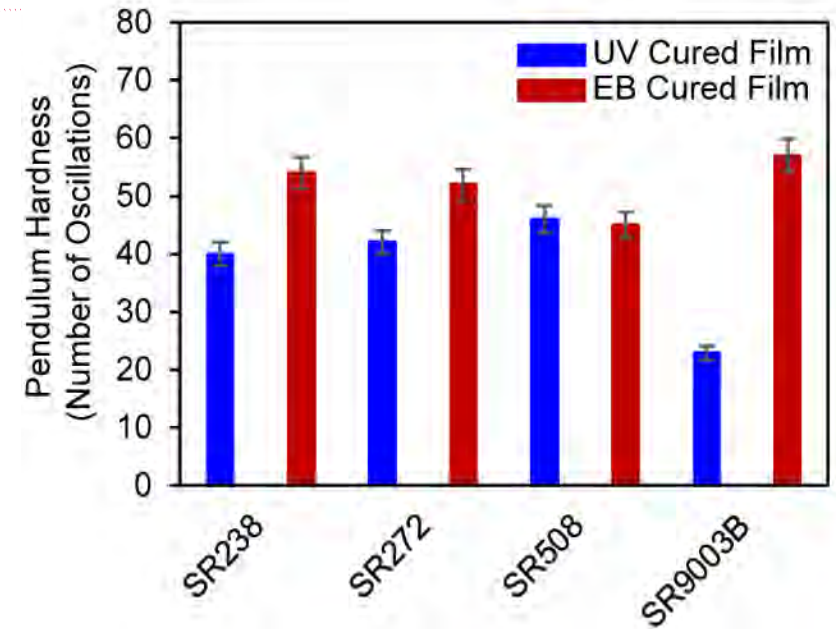
SR272



SR508

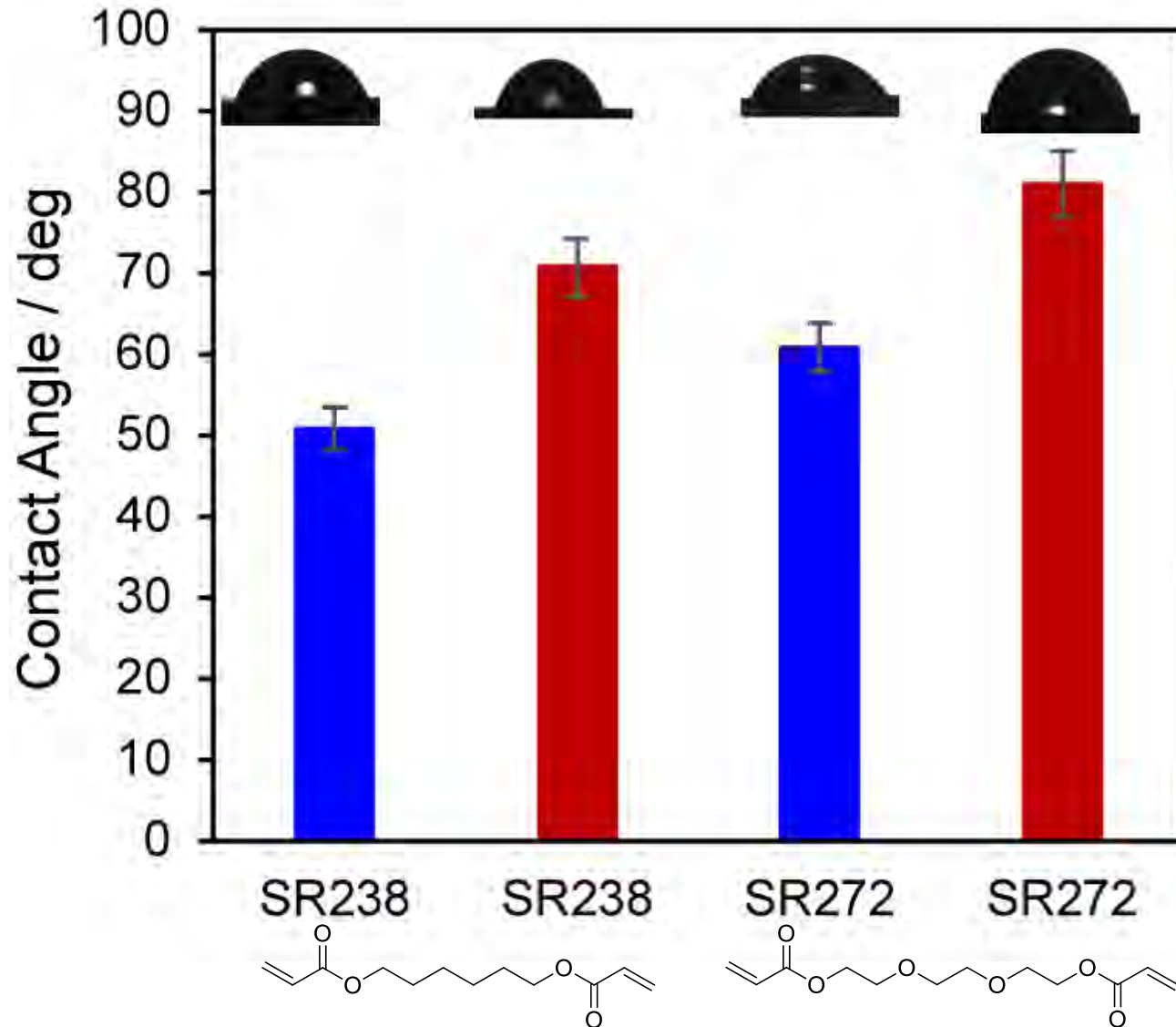


SR9003B



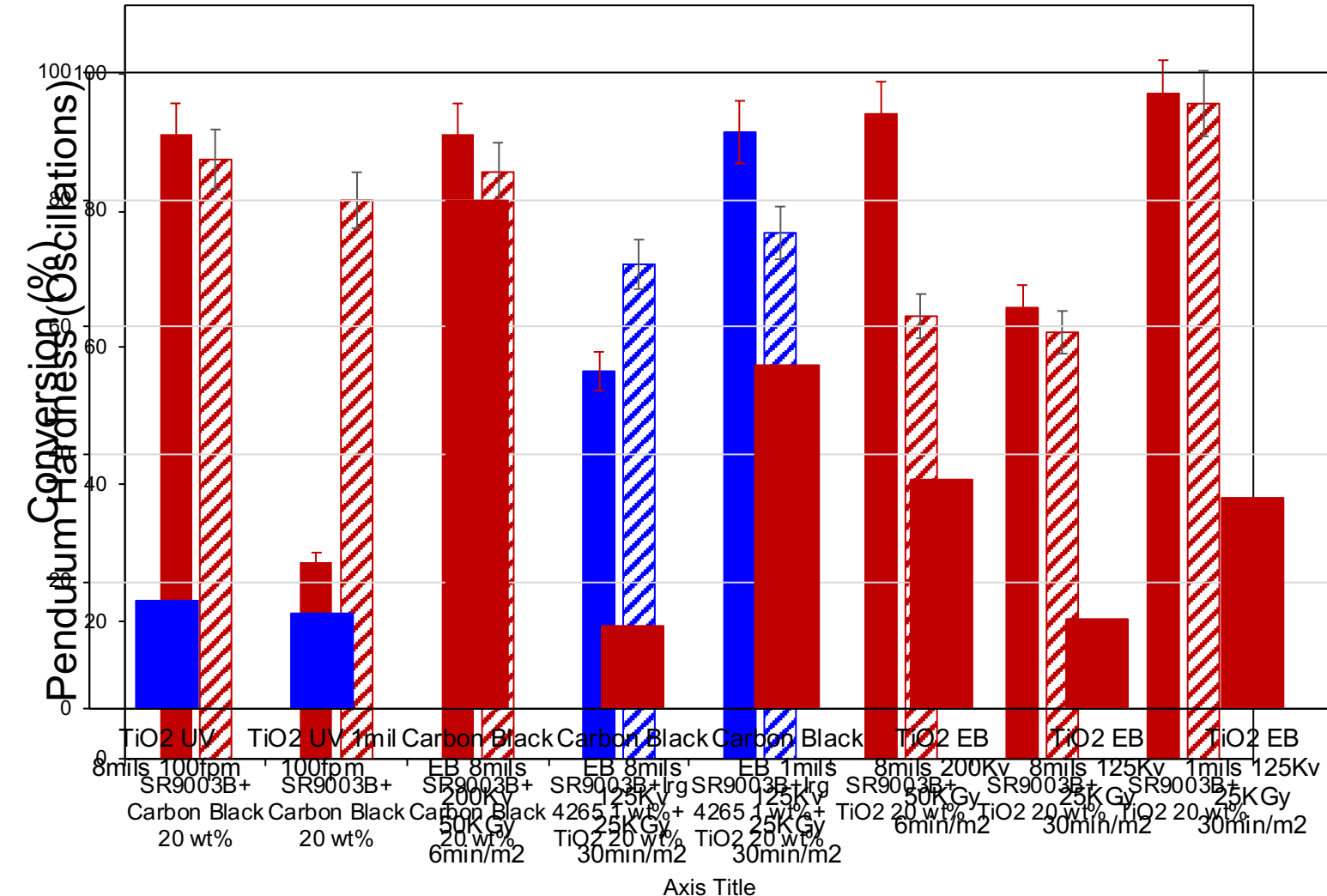
Composition	50 Cycles	100 Cycles	150 Cycles	200 Cycles
SR238 UV	haze	haze	haze	haze
SR238 EB	haze	haze	haze	haze
SR239 UV	*	*	*	*
SR239 EB	*	*	*	*
SR272 UV	haze	haze	haze	haze
SR272 EB	haze	haze	haze	haze
SR508 UV	haze	haze	haze	haze
SR508 EB	haze	haze	haze	haze
SR9003B UV	haze	haze	haze	haze
SR9003B EB	haze	haze	haze	haze

# RADIATION CURING EFFECTS ON SURFACE CHEMISTRY



- ❖ Interactions between EB source and surface chemistry reacts to increase contact angle of water

# EFFECTS OF FILLERS



EB can cured more highly filled systems than UV/Visible light sources

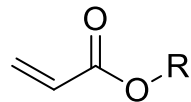
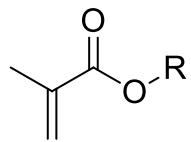
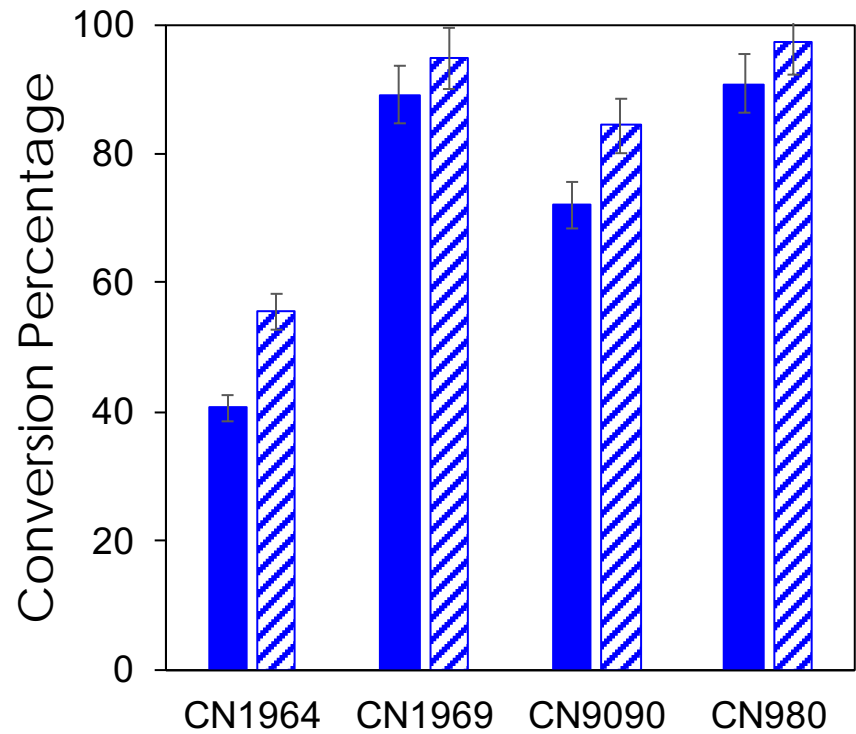
Fillers can have complex interactions in EB curing





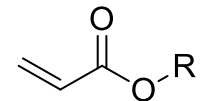
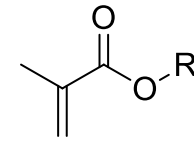
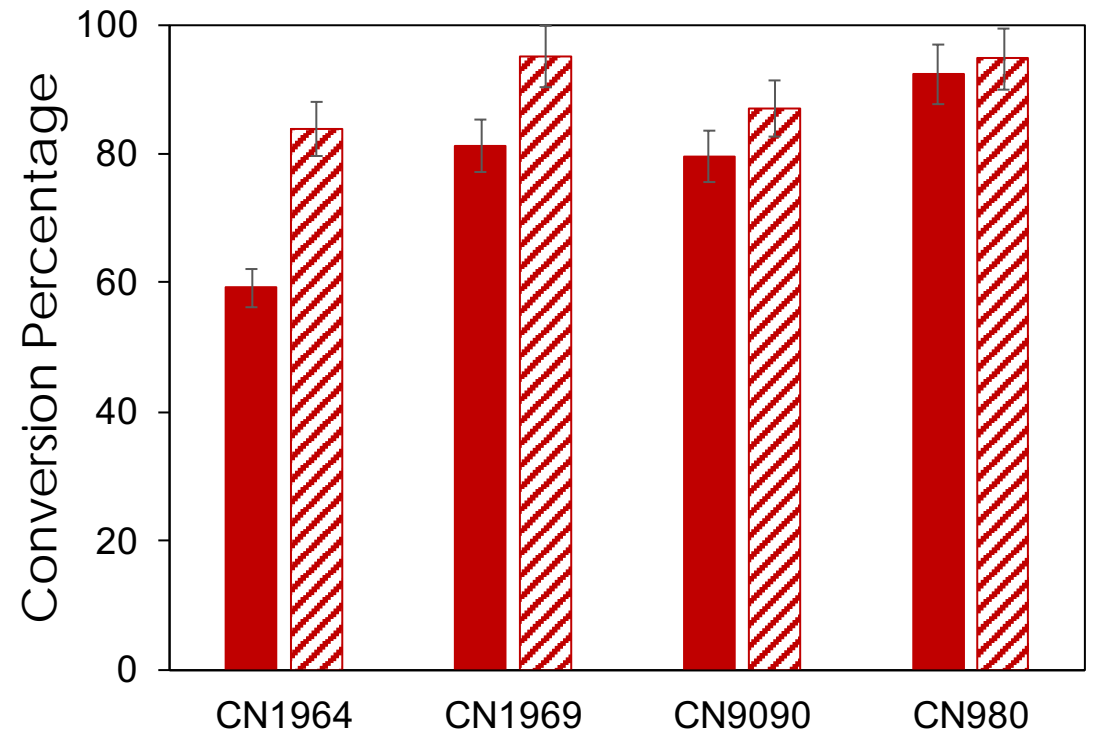
# OLIGOMER STUDIES



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# URETHANE ACRYLATE VS URETHANE METHACRYLATE

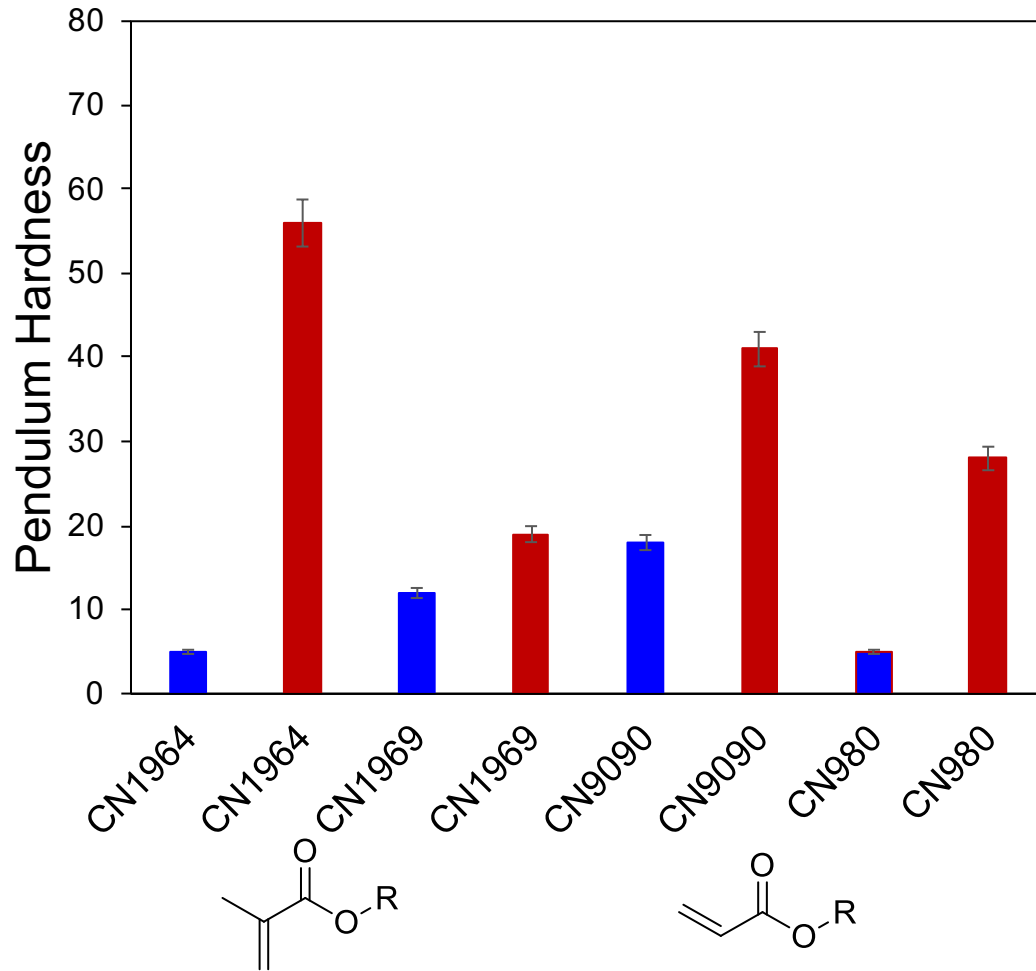


 UV cured film top surface  
 UV cured film bottom surface



 EB cured film top surface  
 EB cured film bottom surface

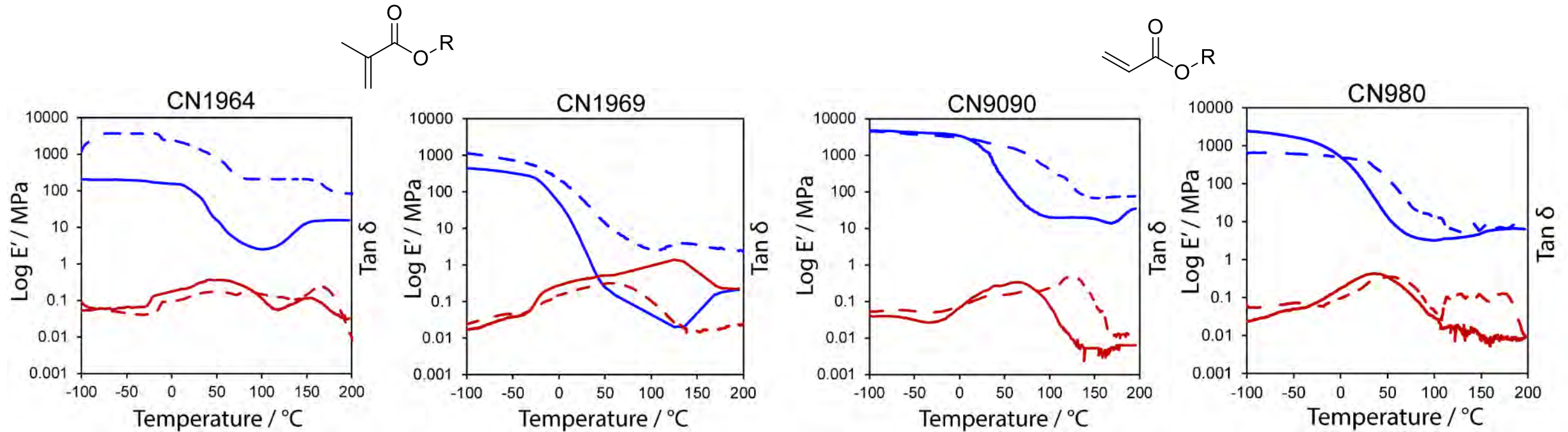
# DIFUNCTIONAL MATERIALS-CURE



Composition	50 Cycles	100 Cycles	150 Cycles	200 Cycles
CN980	no haze	no haze	low haze	haze
CN980	no haze	no haze	no haze	no haze
CN1969	low haze	haze	haze	haze
CN1969	no haze	no haze	no haze	low haze
CN9090	haze	haze	haze	haze
CN9090	no haze	no haze	low haze	haze
CN1964	haze	haze	haze	haze
CN1964	no haze	no haze	no haze	low haze

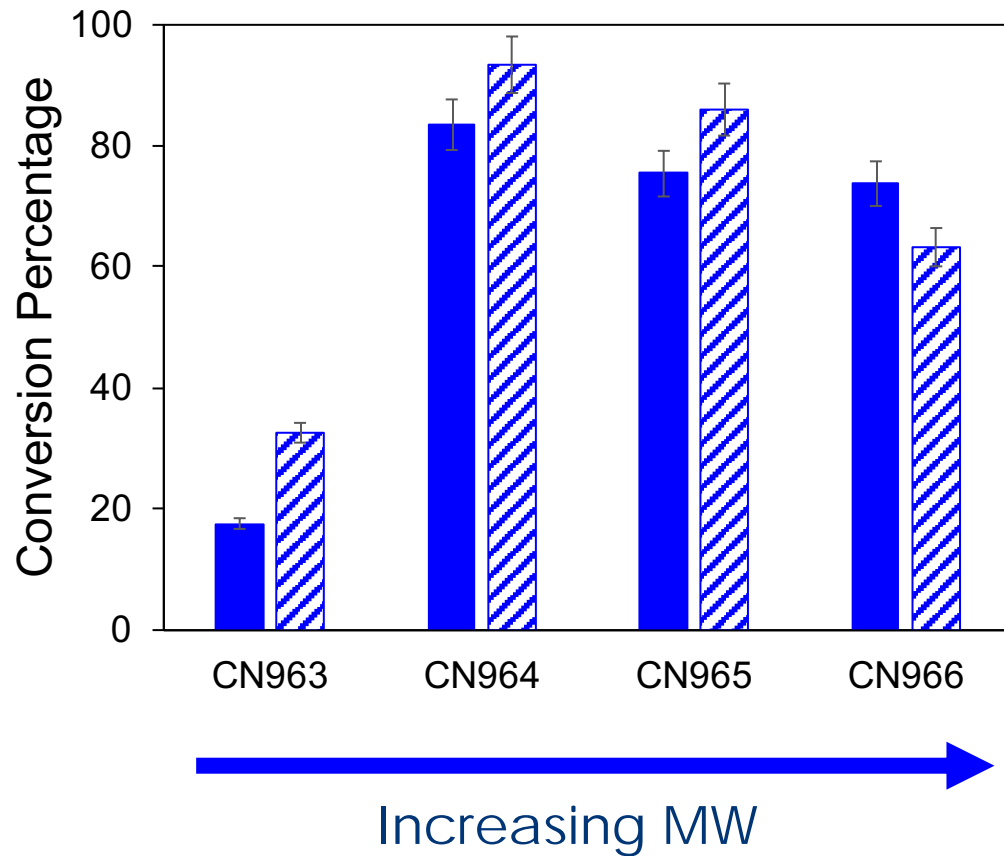
✦ Increased performance of EB materials likely due to increased crosslinking

# POLYURETHANE (METH)ACRYLATE THERMOMECHANICAL STUDIES

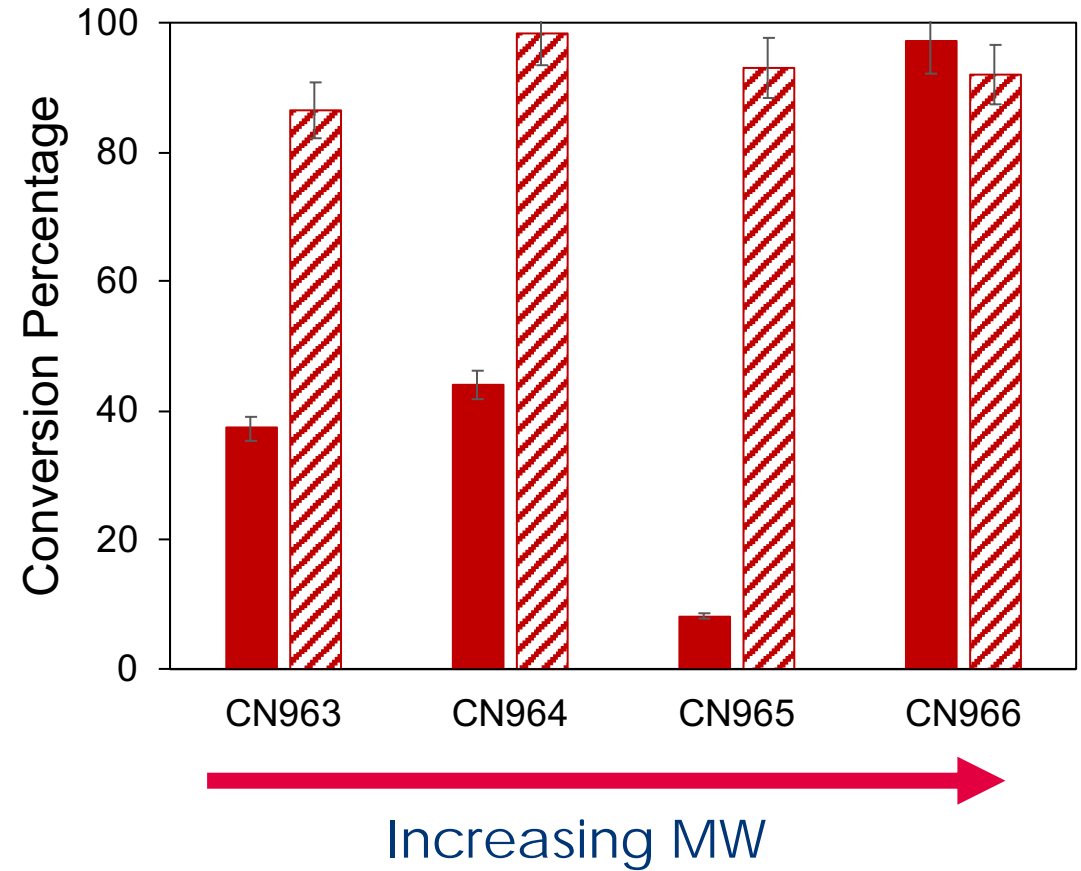


- ❖ UV Cure of methacrylate oligomers show increased storage modulus due to interactions between urethane and polyol backbone chemistry
- ❖ Urethane acrylates show increased  $T_g$  as well as increased crosslinking

# EFFECTS OF URETHANE ACRYLATE MW ON CONVERSION



■ UV cured film top surface  
▨ UV cured film bottom surface

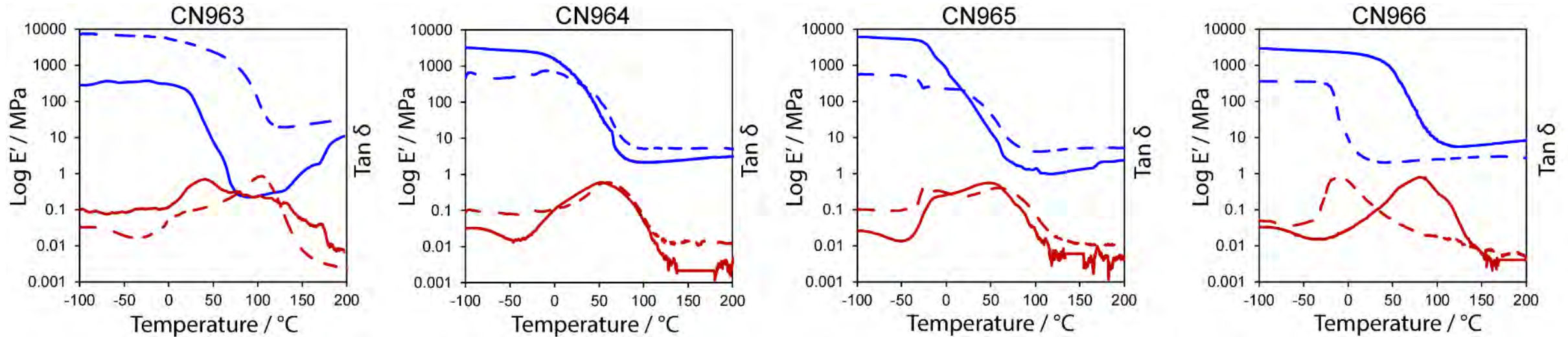


■ EB cured film top surface  
▨ EB cured film bottom surface

# EFFECTS OF POLYURETHANE MOLECULAR WEIGHT

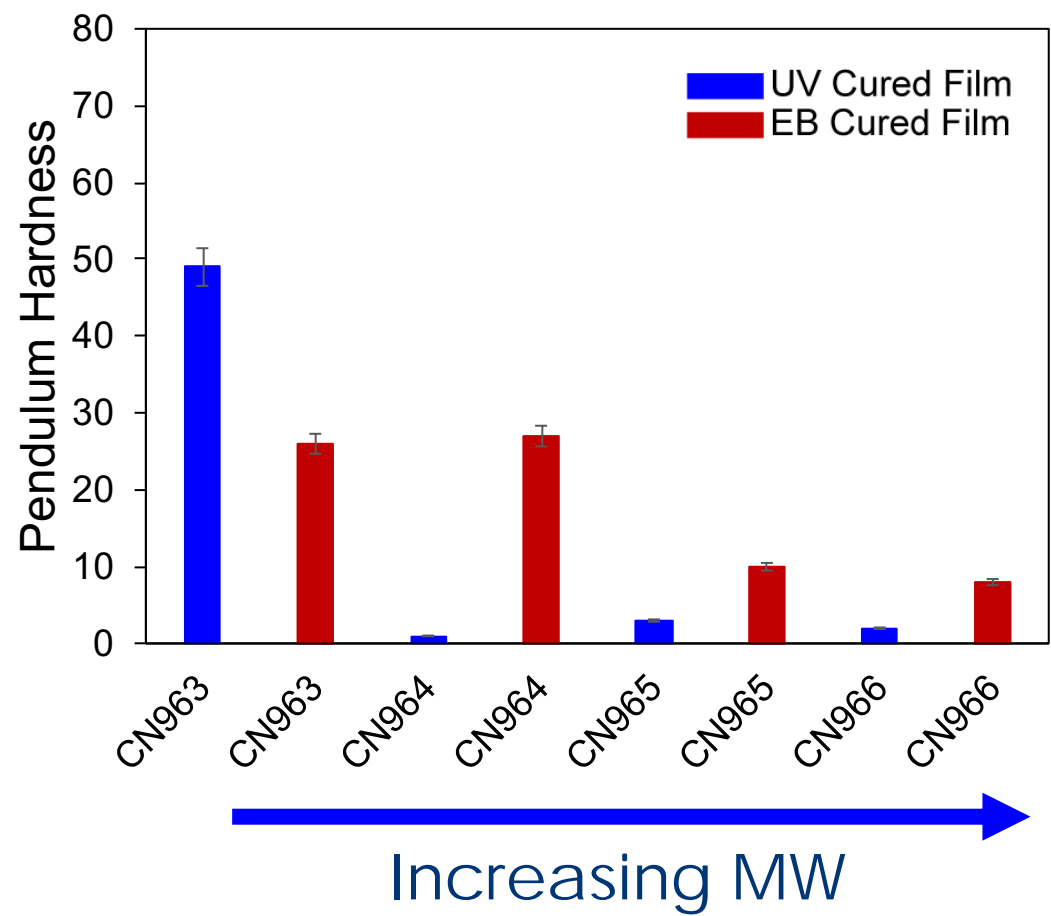


Increasing MW



- ❖ Increasing polyester content leads to interesting EB cure behavior
- ❖ Increasing chain scission lowers  $T_g$  and modulus

# POLYURETHANE ACRYLATE MW HARDNESS



Composition	50 Cycles	100 Cycles	150 Cycles	200 Cycles
CN963 UV	no haze	no haze	no haze	low haze
CN963 EB	low haze	haze	haze	haze
CN964 UV	haze	haze	haze	haze
CN964 EB	no haze	no haze	no haze	no haze
CN965 UV	low haze	haze	haze	haze
CN965 EB	no haze	low haze	haze	haze
CN966 UV	no haze	low haze	haze	haze
CN966 EB	low haze	haze	haze	haze

✦ Balancing polyester content and reactivity is necessary to maximize performance

# ENERGY CURABLE PSA PRODUCTS

Property	UV cured	EB cured
Viscosity at 25°C (cP)	6,650	6,650
Cured PSA Thickness (mil)	2.7	2.1
Curing Method	UV (H Bulb)	EB
Energy (J/cm <sup>2</sup> )	0.49	10 Mrad/175 kV
180° Peel on Stainless Steel; 1 day (lb/in)	7.6	4.2
180° Peel on Polypropylene; 1 day (lb/in)	4.8	4.5
Probe Tack (lb)	2.26	2.06
Room Temp Shear 2 kg (hr)	34	>167
Room Temp Shear 1 kg (hr)	84	>167
SAFT ( °F)	185	435
Refractive Index	1.49	1.49

❖ Modifications to PSA rheology change properties to increase shear and adhesion failure temperature tests.

# MIGRATION IN EB CURABLE FILMS



- Ongoing work to limit migratable species and formation.
- Inhibitors selection is important to limit small molecule species
- Single ppb or no monomers detected

# CONCLUSIONS

- ❖ UV and EB processing create different polymerization methods with significantly different side reactions
- ❖ Polymer backbone and reactive groups further impact the types of side reactions
- ❖ The increased crosslinking in EB processing can lead to much lower levels of migratables in polymer films





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